

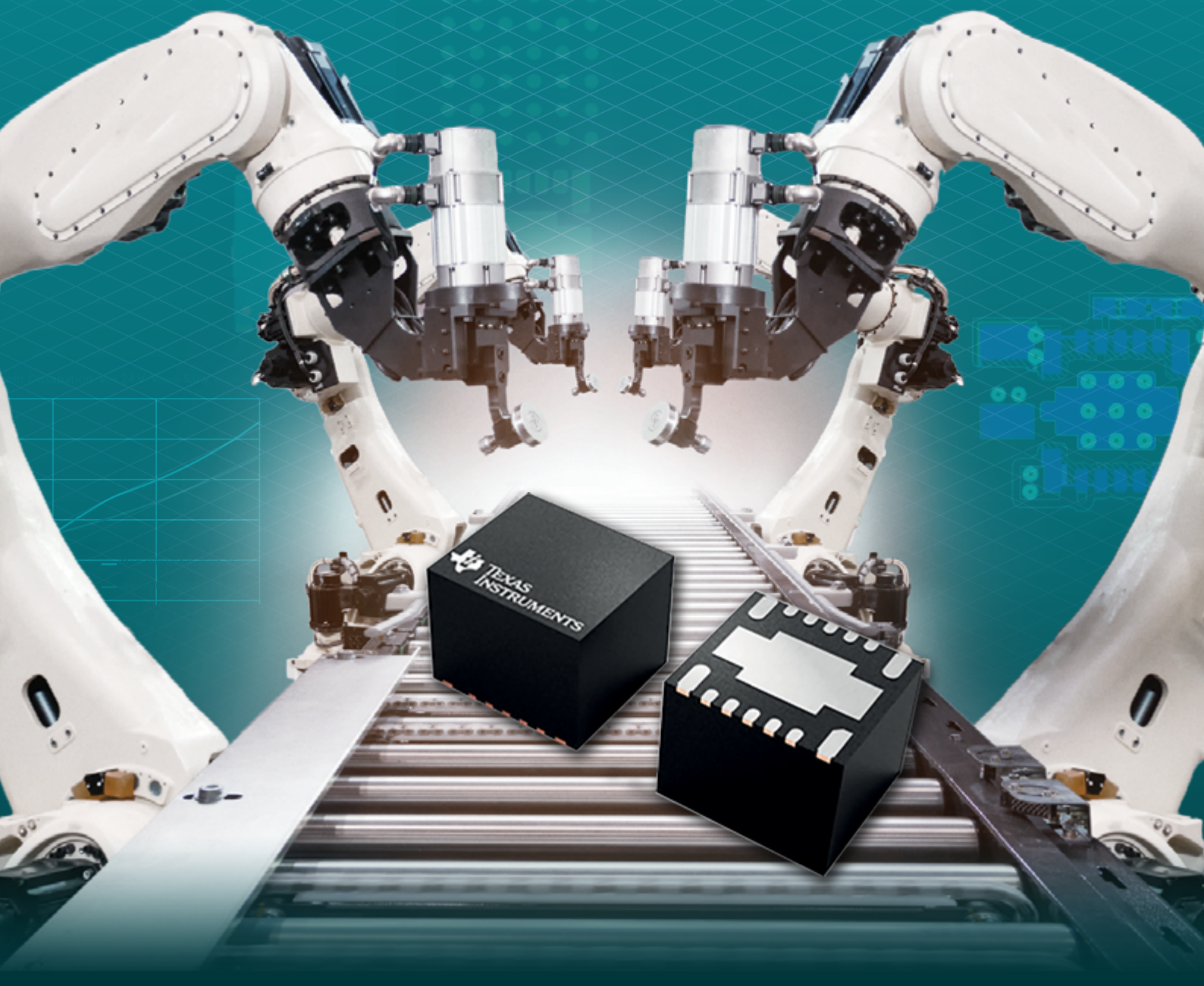
Bodo's Power Systems®

Electronics in Motion and Conversion

September 2020

Small. Efficient. Easy.

Enhanced HotRod™ QFN package helps
shrink power supply footprint by 30%
and improve thermal performance.



CEO Transition Announced



Vincotech announced that its Board of Directors has appointed Eckart Seitter, Senior Vice President of Sales and Marketing, as Vincotech's Chief Executive Officer (CEO) and Chairman of the Board effective October 1, 2020. Eckart Seitter will succeed Vincotech's CEO and Chairman of the Board Joachim Fietz, who will retire from the company and board after 12 successful years as CEO. This smooth CEO transition demonstrates the long-term continuity of the company as a

reliable and trusted partner for its global customers, counting on Eckart Seitter's tremendous business and leadership skills, his strategic

insight and his customer-focused mentality. Eckart Seitter has been with the company for more than 20 years. He became Managing Director Sales and Marketing in 2013, and thus has made a strong contribution to Vincotech's development and success. "Joachim Fietz set exceptionally high standards of achievement during his leadership for more than a decade, and I am very much looking forward to this new challenge to follow him, and to working together with the management team," said Eckart Seitter. "Together, we want to set the course for our further global growth. Our goal is to continue the development of Vincotech, a strong brand within Mitsubishi Electric Corporation, and to sustainably fulfil our primary obligation to serve customer needs quickly and flexibly".

www.vincotech.com

Bringing Disruptive Power Electronics to the Road Track and the Skies

GaN Systems and BrightLoop Converters announced their strategic partnership to develop the latest AC/DC and DC/DC Converter products for electric motorsport and aerospace applications. Leveraging GaN Systems' 650V GaN transistors, BrightLoop produces a range of converters that are smaller, lighter, and more efficient than currently available in the market.

GaN is a key component for applications in industries requiring high power performance and reliability. BrightLoop's most recent family of DCDC converters, including the 1.9 kW, 4.8 kW, and 9.6 kW DCDC converters designed for hybrid and electric racing, incorporates GaN Systems transistors and are around half the size and weight of the company's first generation DCDC converter developed without GaN. BrightLoop continues to make advancements using GaN to



produce lighter and more compact converters.

BrightLoop's DCDC converters are now used in many of the Formula E teams and the winning team from 2019. The converter's function is to power all the low-voltage electronics including pumps, lighting, and radio. Most recently, the World Sporting Consulting (WSC) Group, the premier motorsport event and racing promotion organization overseeing Touring Car Racing (TCR) and ETCR (Electric Touring Car Racing) brands, announced BrightLoop as the sole supplier of DCDC converters for ETCR cars. ETCR is the world's first electric touring car championship, which will begin this summer 2020.

www.gan-systems.com

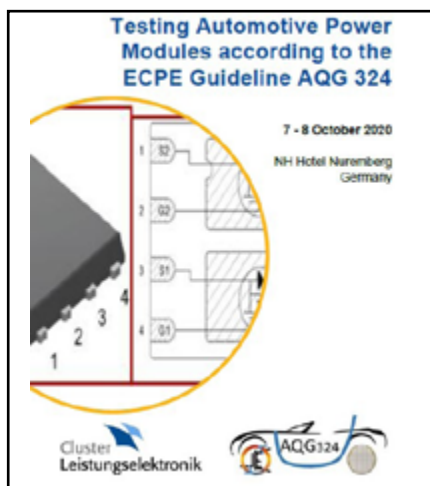
www.brightloop.fr

Tutorial on Testing Automotive Power Modules

The ECPE Guideline AQG 324 is prepared and released by the ECPE Working Group 'Automotive Power Module Qualification' comprising ECPE member companies from the automotive supply chain. The original version is based on the supply specification LV 324 which has been developed by German automotive OEMs together with representatives from the power electronics supplier industry.

The described tests concern the module design as well as the qualification of devices on module level (i.e. the assembly) but not the qualification of semiconductor chips or manufacturing processes. The requirements, test conditions and tests presented in the tutorial essentially refer to power modules based on Si power semiconductors while wide bandgap power semiconductors (e.g. SiC or GaN) are addressed but not yet fully covered by the Guideline.

The Tutorial, 7 - 8 October 2020 in Nuremberg, Germany, with speakers from the AQG 324 Core Team will give practical information and advice how to test power modules



according to the AQG 324 Guideline under comparable conditions. It aims at direct users from beginners to senior experts coming from power module suppliers, automotive tier 1 suppliers or test service and equipment providers.

Course Instructors:

- Peter Dietrich, Richardson RFPD Germany
- Steffen Ewald, Fuji Electric Europe
- Dr. Gabor Farkas, Mentor Graphics
- Frank Heidemann, Mathias Gebhardt, SET
- Dr. Martin Rittner, Robert Bosch
- Stefan Schmitt, Semikron Elektronik
- Prof. Dr. Markus Thoben, Fachhochschule Dortmund

All presentations and discussions will be in English.

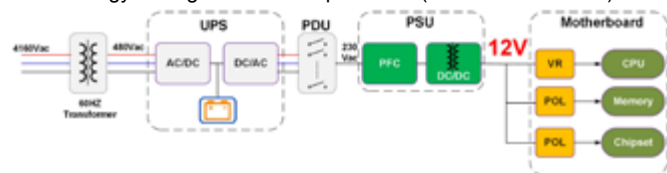
www.ecpe.org

Advantages of 100V GaN in 48V Applications

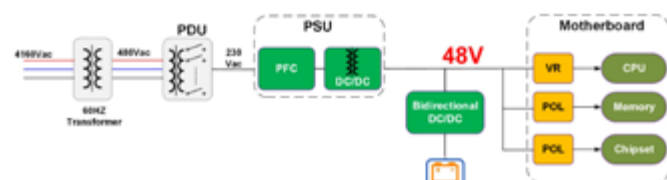
In both consumer electronics and automotive electrification, we are in a cycle of “more” right now. For consumers, more videos, pictures, Insta-this, Snap-that are all driving data demands skyrocketing. In automotive, more features and functions are added every model cycle including entertainment peripherals, safety features, hybrid motion torque and additional and brighter LEDs. Providing “more” requires more power to be delivered. More power is typically constrained by size and/or weight restrictions. This is why a growing number of industries are moving to higher-voltage, 48V distribution versus conventional 12V distribution.

*By Lei Kou, Power Electronics Applications Engineer,
and Juncheng (Lucas) Lu, Applications Engineering Manager, GaN Systems*

Why 48V? I^2R conduction losses in a system can be detrimental to system efficiency and can reduce the power flow to the load effectively given cable, connector and/or PCB limitations. As an example, server processor power has increased from 100W-200W to 400W and higher. Distributing this increased power to multiple server processors creates more losses unless mitigated by higher voltage distribution or larger copper bus bars. The conventional datacenter/server power architecture is illustrated in Figure 1(a), where all major processor/memory devices are powered from a 12V bus. The I^2R loss for a 12V bus is excessive, and there are many energy conversion stages, which reduces the total system efficiency. To mitigate the heavy bus-bar loss and reduce energy conversion stages in the power distribution path, a 48V bus datacenter/server architecture is shown in Figure 1(b). This power architecture has the advantage over current design practices by eliminating online UPS, cables and harness. The trend clearly shows that the power conversion benefits from 48V bus with more energy saving and lower expenditure (CAPEX and OPEX).



a) Conventional power architecture with 12V bus



b) Alternative power architecture with 48V bus

Figure 1: The architecture evolution of datacenter/server from 12V to 48V

With “more power in less area” being the norm, moving from 12V to 48V power distribution using high frequency power transistors allows engineers to meet their efficiency, cost and size/weight metrics.

The GaN Systems 100V product line is a solid solution candidate for 48V applications that meets high frequency, high efficiency, and high-power density power conversion requirements. Compared to MOSFETs, GaN transistors have wide band gap, high electron mobility, and high electron velocity to allow the system switching frequency to be pushed up to high kHz and MHz frequencies to maintain high efficiency and increase power density [1]-[4].

To optimize the system, a deep understanding of conduction and switching losses is required [5]. This information for higher voltage devices, e.g. 650V transistors, can usually be found in the datasheet as well as PLECS/Python simulation models provided by semiconductor companies. However, for 100V devices, the Eon/Eoff data is typically not published because of the difficulty of accurate measurement. An ultra-low parasitics Eon/Eoff measurement platform is described in this article. With this test platform, accurate Eon/Eoff data of 100V GaN Systems devices has been achieved.

GaN Systems provides the switching loss model including PLECS, Python and Excel-based for both 650V and 100V products. GaN Systems 100V GaN products, evaluation boards, modules and the new set of PLECS simulation models provide a comprehensive place to start new system designs.

Accurate switching energy measurement platform for 100V GaN Devices

When comparing transistors with different semiconductor materials, or analyzing trends from a specific manufacturer, the use of a standard figure of merit (FOM) is a useful tool. For example, to compare the $R_{DS(on)} \cdot Q_G$ FOM of a 650V GaN Systems transistor versus a super-junction MOSFET, there is more than a 10x difference in FOM and this has direct implications on system losses. Unlike 650V devices, the difference in FOM between GaN transistors from different suppliers and compared to silicon MOSFETs is not as large. The data below illustrates that additional understanding and measurement of device loss with accurate device loss models is required to determine the real system performance of the transistors in low voltage applications.

To measure the switch current during the switching transition process, a high bandwidth current shunt must be connected in series with the device under test (DUT). The parasitic inductance introduced by a large current shunt causes severe voltage overshoots when compared to the voltage rating of 100V devices. This results in the measured switching energy data being much higher than the value in real-world applications (without a current shunt used for measurement). As a result, power semiconductor vendors rarely publish switching energy data for 100V and below devices.

GaN Systems has designed an ultra-small parasitics Double-Pulse Test (DPT) platform, shown in Figure 2. The parasitic inductance of the power commutation loop is reduced from more than 10nH to 0.8nH, including the large current shunt (model #SSDN-005). When two adjacent conductors are located near each other with opposite current directions, the magnetic flux generated by the two directions of current will cancel each other, reducing the parasitic inductance.

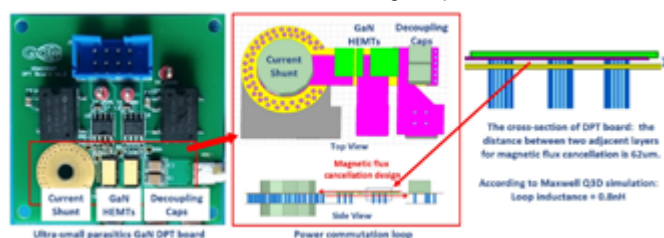


Figure 2: Ultra-small parasitics DPT platform for 100V semiconductor devices

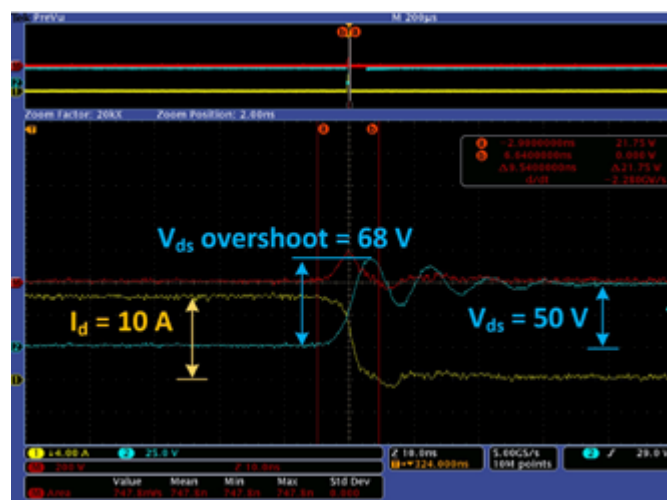


Figure 3: Comparison between the GaN Systems test platform (with Shunt) and other company evaluation board (without Shunt)

The distance between the two adjacent flux canceling layers of the DPT board is 62µm. The simulated power commutation loop inductance, according to ANSYS Q3D software, is 0.8 nH.

The comparison between the GaN Systems' DPT platform and GaN transistor evaluation board for a different supplier, without a current shunt, is shown in Figure 3. Under the same test condition ($V_{ds} = 50V$, $I_d = 10A$, GaN device: GS61008T, $R_{g_on} = 4.7\Omega$, $R_{g_off} = 1\Omega$), the drain-source voltage spike on the DPT board is lower on GaN Systems design compared to the other design (68V versus 80V). This validates the flux cancelling, low parasitics design of the GaN Systems test platform, even with a current shunt in circuit. Had a current shunt been used in the other design, the ringing would be significantly higher than 80V, and measuring Eon/Eoff would be highly inaccurate.

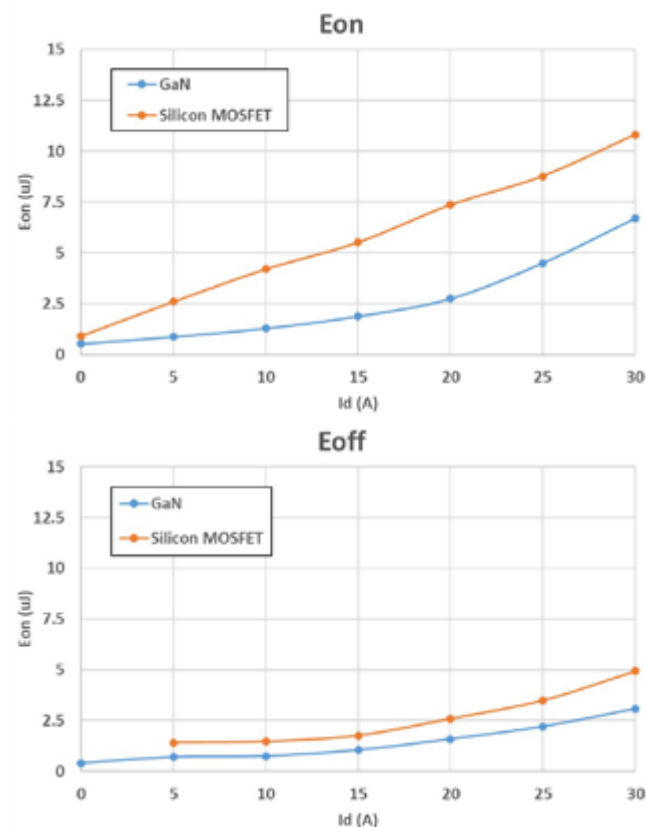


Figure 4: Eon/Eoff comparison between GaN Systems (GS61008T) and a silicon MOSFET

With the GaN Systems switching energy measurement platform, accurate Eon/Eoff data is achieved. A switching energy comparison between a GaN Systems device and a silicon MOSFET was achieved through testing. Both, the GaN transistor (GS61008T) and silicon MOSFET, have similar $R_{DS(on)}$. The results in Figure 4 show the GaN Systems device has lower Eon/Eoff than the silicon MOSFET.

Perhaps a more interesting comparison is between 100V GaN from different suppliers, as shown in Figure 5. Both GaN devices have similar $R_{DS(on)}$ values. However, the GaN Systems device has lower Eon/Eoff.

Figure of Merit

As described above, FOM is sometimes used to compare the in-circuit performance capability of a given device technology in different applications. The following section shows how this can lead to incorrect conclusions with 100V device analysis.

In hard switching applications, two device parameters have major impact on the switching losses: 1) Q_{GD} , the miller charge, controls the voltage rising and falling speed; and 2) Q_{GS} , the gate source charge from the device threshold voltage to the gate plateau voltage, controls the current rising and falling speed. Therefore, the hard switching $FOM = (Q_{GD} + Q_{GS}) * R_{DS(on)}$ is usually used to compare the in-circuit performance capability of different device technologies.

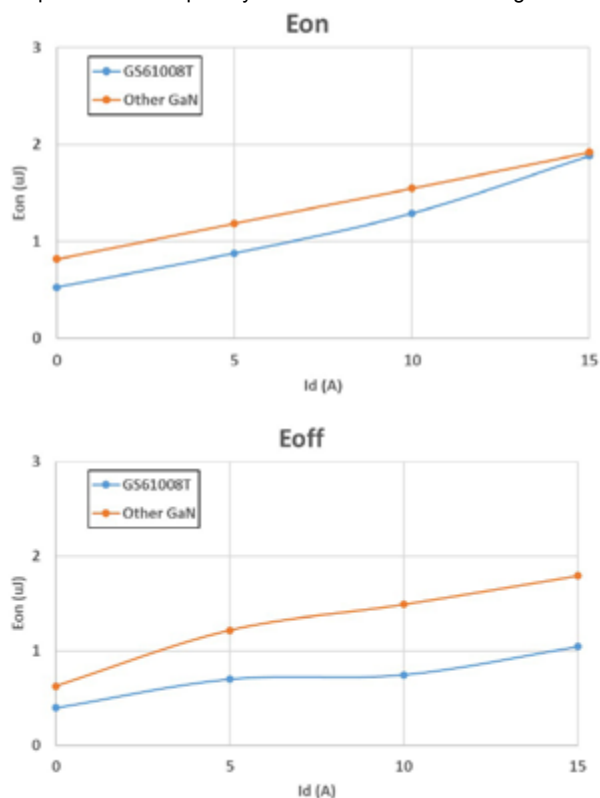


Figure 5: Eon/Eoff comparison between GaN Systems GaN (GS61008T) and other GaN with similar $R_{DS(on)}$

In soft switching application, Q_{OSS} , the output charge, directly impacts the energy required to achieve zero voltage switching (ZVS) and zero current switching (ZCS). Q_G , which is the gate charge, is also a major switching loss characteristic in high frequency soft switching applications. So, to compare parameters that influence the in-circuit performance of different device technologies in soft switching applications, $FOM = (Q_{OSS} + Q_G) * R_{DS(on)}$ is often used.

	GaN Systems GS61008T	GaN Supplier 2	GaN Supplier 3	Silicon MOSFET
$R_{DS(on)}$	7 mΩ	5.6 mΩ	15 mΩ	6 mΩ
Q_{GS}	3.5 nC	1.9 nC	1.3 nC	10 nC
Q_{GD}	1.7 nC	0.8 nC	0.6 nC	6 nC
Q_{OSS}	21.3 nC	25 nC	21 nC	41 nC
Q_G	8 nC	6 nC	3.8 nC	30 nC
Hard switching FOM ($Q_{GS} + Q_{GD}$) * $R_{DS(on)}$	36.4	15.12	43.5	96
Soft switching FOM ($Q_{OSS} + Q_G$) * $R_{DS(on)}$	205.1	173.6	372	426

Table 1: FOM comparison of different semiconductor devices

A FOM comparison of four different semiconductor devices (three GaN transistors and one silicon MOSFET) is shown in Table 1.

According to the FOM comparison table, it can be observed that: 1) GaN devices have a lower FOM than silicon MOSFETs (remember that lower FOM is better); and 2) the product from GaN supplier 2 has the lowest FOM among the GaN devices. Interestingly, in this case, the device with the lowest FOM does not have the best performance in the targeted application. Recall from the Eon/Eoff analysis that the GaN Systems device has lower losses than the other GaN device. In addition to the Eon/Eoff losses, the thermal performance also contributes to overall functionality.

Thermal performance and system level comparison

In most applications, FOM and loss analysis is important but not the complete picture to achieve higher efficiency. Device thermal performance is also a very important factor to determine the system efficiency. GaN transistors have a positive temperature co-efficient $R_{DS(on)}$ characteristic. Also, switching losses increase as junction temperature increases. Therefore, devices with good FOM but difficulty managing thermal performance can have higher losses and be limited in efficiency and/or power.



Figure 6: Thermal resistance comparison

As seen in Table 1, one GaN device has a better FOM compared to the GaN Systems device. However, there are some high power thermal challenges due to the “chip-scale” style package of the device. As shown in Figure 6, the GaN Systems device, in a low parasitic, thermally enhanced package, operates at ~50% lower $T_{JUNCTION}$ versus the chip-scale type device. To demonstrate the importance of thermals in an application, a system level comparison is presented with the four different semiconductor devices from Table 1 used on identical 48V to 12V evaluation boards.

The maximum current versus switching frequency in Figure 7 shows that the GaN Systems' device has 2.3x higher output power at 1MHz switching frequency compared to the other GaN devices and the silicon MOSFET.

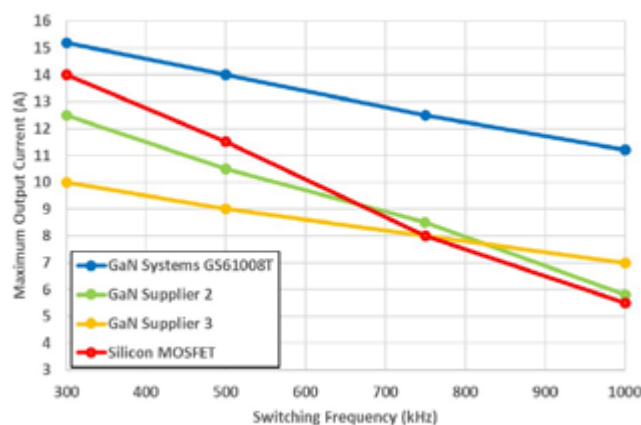


Figure 7: Maximum current comparison vs. different switching frequency

The efficiency curve in Figure 8 shows that:

- GaN transistors have much better efficiency over silicon MOSFETs;
- the GaN Systems device has the highest efficiency;
- the GaN Systems device can support much higher power compared to others.

Note that the tests were stopped when the specific device showed signs of thermal starting to limit output power. In this 48V to 12 V application, the data illustrates that a combination of FOM, Eon/Eoff and thermal performance must be considered to determine the best performance.

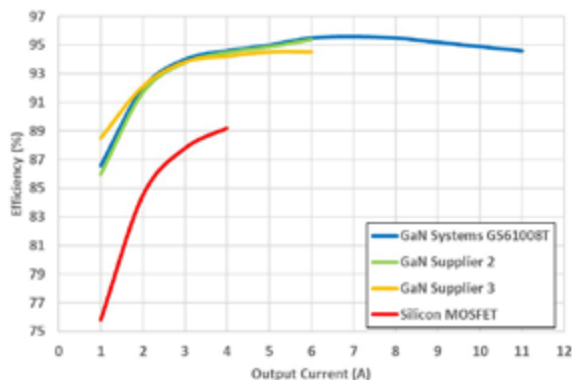


Figure 8: Efficiency comparison of different semiconductor solutions

Conclusion

GaN power transistors can switch at higher frequencies than traditional silicon MOSFETs and therefore are excellent power semiconductor candidates for 48V application challenges. System loss analysis is critical to optimize the power system design. To achieve accurate

Eon/Eoff data for 100V GaN devices, GaN Systems has developed an ultra-low parasitics double-pulse test platform. The Eon/Eoff data acquired from this test platform shows that GaN transistors have lower Eon/Eoff than silicon MOSFETs and other GaN power devices. A system level comparison in a 48V to 12V application shows that 1) GaN Systems solutions achieve much higher efficiency than other GaN or silicon solutions, and 2) important factors such as Eon/Eoff loss analysis, packaging and thermal effects must be accounted for to achieve high system efficiency.

References

1. K. J. Chen, et al., "GaN-on-Si power technology: devices and applications," IEEE Transactions on Electron Devices, vol. 64, no. 3, pp. 779-795, Mar. 2017.
2. F. C. Lee, Q. Li, Z. Liu, Y. Yang, C. Fei and M. Mu, "Application of GaN devices for 1 kW server power supply with integrated magnetics," in CPSS Transactions on Power Electronics and Applications, vol. 1, no. 1, pp. 3-12, Dec. 2016.
3. J. Strydom, D. Reusch, "Design and evaluation of a 10 MHz gallium nitride based 42 V DC-DC converter," in IEEE 2014 Applied Power Electronics Conference and Exposition, 2014, pp. 1510-1516.
4. D. Liu, Y. Wang, Z. Chen, and B. Li, "A buck converter with cost-effective GaN/Si hybrid switches and CRM operation for high-efficiency and high-power-density applications," in IEEE 2018 Southern Power Electronics Conference, 2018, pp. 1-6.
5. W. Chen, et al. "Impact of parasitic elements on power loss in GaN-based low-voltage and high current DC-DC buck converter," in IEEE 2018 International Conference on Electrical and Electronics Engineering, 2018, pp. 294-298.

www.gansystems.com



AsahiKASEI

CURRENT SENSOR CZ-37XX FAMILY



60A_{RMS} EFFECTIVE CURRENT

0.5%_{F.S.} TOTAL ACCURACY

1μS RESPONSE

UL61800-5-1



www.akm.com